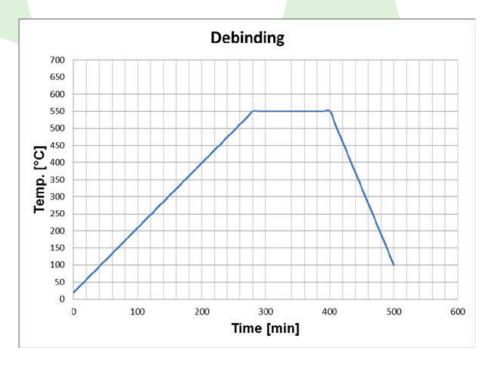


TECHNICAL DATA SHEET

Ready-to-Press (RTP) Silicon Nitride Powder / α -Si $_3$ N $_4$ Processing Manual

Powder Density:	0.9-1.0	g/cm³
Molding: Uniaxial-Pressing: Cold Isostatic Pressing (CIP): *Recommendation: first step uniaxial pressing second step CIPing	200 1700-200	bar bar
Green Density:	~ 1.92	g/cm³
Debinding: *air atmosphere, 2h	~ 550	°C



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TECHNICAL DATA SHEET

Ready-to-Press (RTP) Silicon Nitride Powder / α -Si $_3$ N $_4$ Processing Manual

Sintering:

Area 1: Standard Atmosphere or Nitrogen Atmosphere

Area 2: Short Time Vacuum 0.4 mbar, followed by Nitrogen Atmosphere 1-2 bar,

heating start

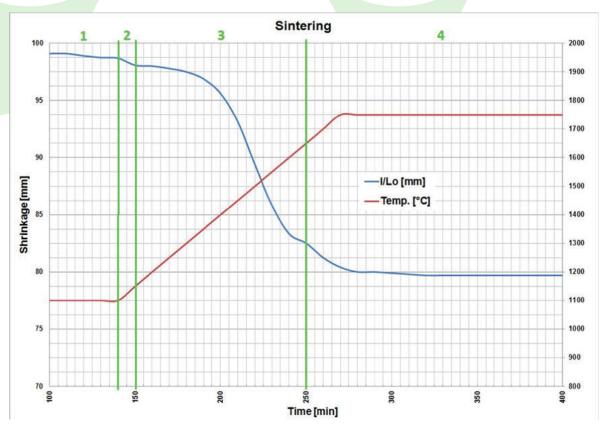
Area 3: Heating Rate ~5 K/min until the theoretical density of > 93 % is reached;

usually between 1550 - 1650°C

Area 4: Increase the Nitrogen Pressure to 10-50 bar until the maximal temperature

(1700 - 1850°C) is reach; followed by holding time of 2-3 h

Density: ~ 3.23 g/cm³



^{*} Sintering conditions can differ to the above mentioned depending on the size of the structures and the type of the sintering furnace. In addition, the sintering conditions can be adjusted to the tangled material properties.

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